009695860 WPI Acc No: 1993-389413/199349 Related WPI Acc No: 1993-274695 XRAM Acc No: C93-173149 XRPX Acc No: N93-300719 Positive radiation sensitive resin compsn. - contains alkali soluble resin, radiation sensittive acid forming agent, resin solubility controlling agent, and cpd. contg. basic nitrogen gp. and acid gp. Patent Assignee: JAPAN SYNTHETIC RUBBER CO LTD (JAPS ) Inventor: KOBAYASHI E; MIURA T; MURATA M; OTA T; YUMOTO Y Number of Countries: 002 Number of Patents: 003 Patent Family: Kind Week Date Patent No Kind Date Applicat No 199349 B JP 5289340 19931105 JP 92116722 Α 19920410 Α Α 19930219 199703 US 5580695 19961203 US 9319871 A US 94339289 Α 19941110 199953 B2 19991110 JP 92116722 Α 19920410 JP 2976414 Priority Applications (No Type Date): JP 92116722 A 19920410; JP 9273169 A 19920225 Patent Details: Patent No Kind Lan Pg Main IPC Filing Notes 18 G03F-007/039 JP 5289340 Α Cont of application US 9319871 13 G03C-001/73 US 5580695 JP 2976414 B2 16 GO3F-007/004 Previous Publ. patent JP 5289340 Abstract (Basic): JP 5289340 A The compsn. includes (1) alkali soluble resin, (2) radiation sensitive acid forming agent, (3) a cpd. able to control the alkali solubility of the alkali soluble resin of (1), decomposable by the existence of acid for lowering or eliminating the alkali solubility of (1) controlling effect, or generating the property for accelerating the alkali solubility of (1), and (4) is cpd. with a nitrogen-contg. basic gp. and acid gp. in a molecule. The compsn. includes (1) alkalit insoluble or hardly soluble resin

The compsn. includes (1) alkalit insoluble or hardly soluble resin having at least one kind of acid dissociation gp. selected from substd. methyl gp., 1-substd. ethyl gp., gelmyl gp., alkoxycarbonyl gp., acyl gp. and silyl gp., and becoming alkali soluble when the above gp. dissociates the acid, and (3) a cpd. having a nitrogen-contg. basic gp. and acid gp. in the molecule.

USE/ADVANTAGE — Superior developing property, pattern forming property and definition. Used for the irradiation by radiation of wavelength less than far UV.

Dwg. 0/0